



2625
CH

PATENT
Customer No. 22,852
Attorney Docket No. 4329.2481

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
Toshiya KOTANI et al.)
Application No.: 09/748,227)
Filed: December 27, 2000) Group Art Unit: 2625
For: MASK PATTERN CORRECTION)
METHOD, MASK PATTERN) Examiner: Kanjibhai B. Patel
CREATION SYSTEM USING THE)
CORRECTION METHOD, AND)
COMPUTER-READABLE)
RECORDING MEDIUM)

RECEIVED

JUL 14 2004

Technology Center 2600

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

PETITION FOR EXTENSION OF TIME

Applicants hereby petition for a one month extension of time to reply to the Office Action of March 9, 2004. A fee of \$110.00 is enclosed.

Please grant any extensions of time required to enter this response and charge any additional required fees to our deposit account 06-0916.

Respectfully submitted,

FINNEGAN, HENDERSON, FARABOW,
GARRETT & DUNNER, L.L.P.

Dated: July 7, 2004

By: Elizabeth A. Niemeyer
Elizabeth A. Niemeyer
Reg. No. 52,070